

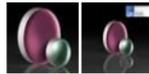
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## 25.4mm Dia. 20°, 780nm Highly-Dispersive Ultrafast Mirror

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UltraFast Innovations (UFI) 800nm Highly-Dispersive Ultrafast Mirrors



Stock #17-067 **5 In Stock**

- 1 + €936<sup>00</sup>

**ADD TO CART**

### Volume Pricing

Qty 1-9	€936,00 each
Qty 10+	€674,00 each
Need More?	<a href="#">Request Quote</a>

ⓘ Prices shown are exclusive of VAT/local taxes

### Product Downloads

#### General

Laser Mirror

Type:

HD1608

Model Number:

## Physical & Mechanical Properties

Wedge Angle (arcmin):

10 ±5

Clear Aperture (%):

80

Back Surface:

Commercial Polish

Diameter (mm):

25.40 +0.0/-0.5

Thickness (mm):

6.35 ±0.20

## Optical Properties

Reflection at DWL (%):

>99.8% (typical, p-polarization)

Coating Specification:

$R_{avg} >99.8\%$ ,  $GDD = -300 \text{ fs}^2$  @ 720 - 840nm (p-polarization)

$R_{abs} >99.8\%$  @ 780nm (typical, p-polarization)

GDD Specification:

$-300 \text{ fs}^2$  @ 740 - 840nm

Wavelength Range (nm):

720 - 840

Irregularity (P-V) @ 632.8nm:

λ/10

Coating Type:

Dielectric

Coating:

Ultrafast (740-840nm)

Design Wavelength DWL (nm):

780

Angle of Incidence (°):

20

Substrate:

[Fused Silica](#) (Corning 7980)

## Regulatory Compliance

RoHS 2015:

[Compliant](#)

Certificate of Conformance:

[View](#)

Reach 235:

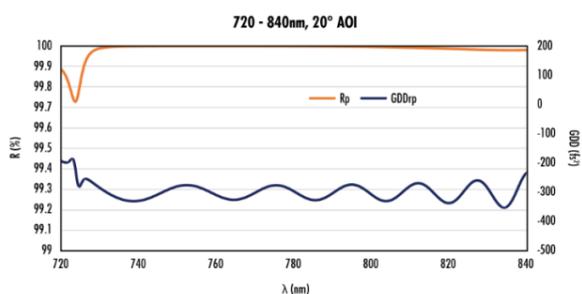
[Compliant](#)

## Product Details

- Reflection >99.8% (P-polarization) at 720 – 840nm or 780 – 830nm
- Low Group Delay Dispersion at 5° or 20° AOIs
- Ideal for Pulse Compression of Ti:sapphire Ultrafast Lasers
- [Low GDD Mirrors](#) Also Available

UltraFast Innovations (UFI) 780 and 800nm Highly-Dispersive Ultrafast Mirrors feature an optimized multilayer ultrafast chirped coating based on dispersive optical interference that provides a low group delay dispersion (GDD) and high reflectance. These ultrafast mirrors provide GDDs as low as  $-1300 \text{ fs}^2$  and greater than 99.8% reflectivity for p-polarization. The highly-dispersive design of these ultrafast mirrors offers control of third and higher order dispersions, and provides high beam stability at either 5° or 20° angle of incidence. UltraFast Innovations (UFI) 780 and 800nm Highly-Dispersive Ultrafast Mirrors are ideal for pulse compression and dispersion compensation of ultrafast pulses, such as Ti:sapphire lasers. Standard imperial sizes are available, featuring fused silica substrates.

## Technical Information



## Custom

Edmund Optics offers comprehensive custom manufacturing services for optical and imaging components tailored to your specific application requirements. Whether in the prototyping phase or preparing for full-scale production, we provide flexible solutions to meet your needs. Our experienced engineers are here to assist—from concept to completion.

Our capabilities include:

- Custom dimensions, materials, coatings, and more
- High-precision surface quality and flatness
- Tight tolerances and complex geometries
- Scalable production—from prototype to volume

Learn more about our [custom manufacturing capabilities](#) or submit an inquiry [here](#).

## Compatible Mounts

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